

L Numb r	Hits	Search Text	DB	Time stamp
108	24107	nucleation	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/14 15:23
109	114	nucleation and (reoxide or re-oxide or reoxidation or re-oxidation)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/14 15:23
110	69	nucleation and (reoxide or re-oxide or reoxidation or re-oxidation) and nitride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/14 15:24
111	12	nucleation same (reoxide or re-oxide or reoxidation or re-oxidation) same nitride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/14 15:26
112	1	nucleation near10 (reoxide or re-oxide or reoxidation or re-oxidation) near10 nitride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/14 15:24
113	2	nucleation same (reoxide or re-oxide or reoxidation or re-oxidation) same nitride same trap	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/14 15:27
-	16	nitride same (re-oxide or reoxide)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:00
-	1	(nitride same (re-oxide or reoxide)).clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:00
-	0	(nitride or SiN) and (reoxide or re-oxide) and (electron near trap)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:01
-	0	(nitride or SiN) and (r oxide or r - xid) and (electr n near10 trap)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:02

-	16	nitride near oxid near di lectric near capacitor	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:02
-	435	nitrid near5 xid near5 di l ctric n ar capacitor	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:02
-	1	(nitride near5 oxide near5 dielectric near capacitor) and (electron near trap)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:07
-	4	(nitride near5 oxide near5 dielectric near capacitor) and (electron near2 (trap or trapping or trapped))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:08
-	3	(nitride adj layer) and ((reoxide or re-oxide) adj layer)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:09
-	0	((nitride adj layer) and ((reoxide or re-oxide) adj layer)) and (trap or trapped or trapping)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:10
-	3	((SiN or nitride) adj layer) and ((reoxide or re-oxide) adj layer)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/09/03 15:10